A New Guide to Thermally Optimized Doped Oxides Monolayer Spray-Grown Solar Cells: The Amlouk-Boubaker Optothermal Expansivity ψ_{AB}

M. Benhaliliba¹, C.E. Benouis¹,

K. Boubaker², M. Amlouk² and A. Amlouk²

¹*Physics Department, Sciences Faculty, Oran University of Sciences and Technology
Mohamed Boudiaf- USTOMB, POBOX 1505 Mnaouer- Oran,*

²*Unité de Physique des dispositifs à Semi-conducteurs UPDS,
Faculté des Sciences de Tunis, Campus Universitaire 2092 Tunis,*

¹*Algeria*

²*Tunisia*

1. Introduction

PVC Photovoltaic solar cells are unanimously recognized to be one of the alternative renewable energy sources to supplement power generation using fossils. It is also recognized that semiconductors layered films technology, in reducing production costs, should rapidly expand high-scale commercialization.

Despite the excellent achievements made with the earliest used materials, it is also predicted that other materials may, in the next few decades, have advantages over these front-runners. The factors that should be considered in developing new PVC materials include:

- Band gaps matching the solar spectrum
- Low-cost deposition/incorporation methods
- Abundance of the elements
- Non toxicity and environmental concerns,

Silicon-based cells as well as the recently experimented polymer and dye solar cells could hardly fit all these conditions. Transparent conducting oxides as ZnO, SnO₂ as well as doped oxides could be good alternative candidates.

In this context, the optothermal expansivity is proposed as a new parameter and a guide to optimize the recently implemented oxide monolayer spray-grown solar cells.

2. Solar cells technologies and design recent challenges

In spite of better performance of traditional junction-based solar cells, during the past few decades, reports have appeared in literature that describe the construction of cells based metal-oxides (Bauer et al., 2001; Sayamar et al., 1994; He et al., 1999; Tennakone et al., 1999;

Bandara & Tennakone, 2001) and composite nanocrystalline materials (Palomares et al., 2003; Kay & Gratzel, 2002). Since that time, several other semiconductors have been tested with less success.

Recent challenges concerning newly designed solar cells are namely Band-gap concerns, cost, abundance and environmental concerns.

2.1 Band gaps matching the solar spectrum

The recently adopted layered structure of PVC raised the problem of solar spectrum matching (Fig.1) as well as lattice mismatch at early stages. In fact, the heterogeneous structure: Contact/window layer/buffer layer/Contact causes at least three differently structured surfaces to adhere under permanent constraints. It is known that the electronic band gap is the common and initial choice-relevant parameter in solar cells sensitive parts design. It is commonly defined as the energy range where no electron states exist. It is also defined as the energy difference between the top of the valence band and the bottom of the conduction band in semiconductors. It is generally evaluated by the amount of energy required to free an outer shell electron the manner it becomes a mobile charge carrier. Since the band gap of a given material determines what portion of the solar spectrum it absorbs, it is important to choose the appropriate compound matching the incident energy range. The choice of appropriated materials on the single basis of the electronic band gap is becoming controversial due the narrow efficient solar spectrum width, along with new thermal and mechanical requirements. It is rare to have a complete concordance between adjacent crystalline structures particularly in band gap sense.

Fig. 1. Solar spectrum

For example, in silicon-based solar cells, recombination occurring at contact surfaces at which there are dangling silicon bonds (Wu, 2005) is generally caused by material/phase discontinuities. This phenomenon limits cell efficiency and decreases conversion quality.

2.2 Low-cost deposition/incorporation methods

Deposition techniques and incorporation methods have been developed drastically and several deposition improved methods have been investigated for fabrication of solar cells at high deposition rates (0.9 to 2.0 nm/s), such as hot wire CVD, high frequency and microwave PECVD, and expanding thermal plasma CVD. Parallel to these improvements, vacuum conditions and chemical processes cost increased the manner that serial fabrication becomes sometimes limited. Nowadays, it is expected that low processing temperature allow using a wide range of low-cost substrates such as glass sheet, polymer foil or metal. These features has made the second-generation low- cost metal-oxides thin-film solar cells promising candidates for solar applications.

2.3 Abundance of the elements

The first challenge for PV cells designer is undoubtedly the abundance of materials for buffer and window layers. The ratio of abundance i. e. of Tungsten-to-Indium is around 104, that of Zinc-to-Tin is around 40. Although efficiency of Indium and Gallium as active doping agents has been demonstrated and exploited (Abe & Ishiyama, 2006; Lim et al., 2005), their abundance had decreased drastically (510 and 80 tons, respectively as reported by U.S. Geological Survey 2008) with the last decades' exploitation.

2.4 Non toxicity and environmental concerns

Among materials being used, cadmium junctions (Cd) and selenium (Se) are presumed to cause serious health and environmental problems. Risks vary considerably with concentration and exposure duration. Other candidate materials haven't gone through enough tests to show reassuring safety levels (Amlouk, 2010).

3. Materials optimisation

3.1 Primal selection protocols

Cost and toxicity concerns led to less and less use of Se and Cd-like materials. Additionally, increasing interest in conjoint heat-light conversion took some bad heat-conducting materials out from consideration. Selection protocols are becoming more concentrated on thermal, mechanical and opto-electric performance.

Since thermal conductivity, specific heat and thermal diffusivity has always been considered as material intrinsic properties, while absorbance and reflexivity depend on both material and excitation, there was a need of establishing advanced physical parameters bringing these proprieties together.

3.2 Opto-thermal analysis

The Amlouk-Boubaker optothermal expansivity is defined by:

$$\psi_{AB} = \frac{D}{\hat{\alpha}} \quad (1)$$

Where D is the thermal diffusivity and $\hat{\alpha}$ is the effective absorptivity, defined in the next section.

3.2.1 The effective absorptivity

The effective absorptivity $\hat{\alpha}$ is defined as the mean normalized absorbance weighted by $I(\tilde{\lambda})_{AM1.5}$, the solar standard irradiance, with $\tilde{\lambda}$: the normalised solar spectrum wavelength:

$$\left\{ \begin{array}{l} \tilde{\lambda} = \frac{\lambda - \lambda_{\min}}{\lambda_{\max} - \lambda_{\min}} \\ \lambda_{\min} = 200.0 \text{ nm} ; \lambda_{\max} = 1800.0 \text{ nm.} \end{array} \right. \quad (2)$$

and :

$$\hat{\alpha} = \frac{\int_0^1 I(\tilde{\lambda})_{AM1.5} \times \alpha(\tilde{\lambda}) d\tilde{\lambda}}{\int_0^1 I(\tilde{\lambda})_{AM1.5} d\tilde{\lambda}} \quad (3)$$

where: $I(\tilde{\lambda})_{AM1.5}$ is the Reference Solar Spectral Irradiance.

The normalized absorbance spectrum $\alpha(\tilde{\lambda})$ is deduced from the Boubaker polynomials Expansion Scheme *BPES* (Oyedum et al., 2009; Zhang et al., 2009, 2010a, 2010b; Ghrib et al., 2007; Slama et al., 2008; Zhao et al., 2008; Awojoyogbe and Boubaker, 2009; Ghanouchi et al., 2008; Fridjine et al., 2009; Tabatabaei et al., 2009; Belhadj et al., 2009; Lazzez et al., 2009; Guezmir et al., 2009; Yıldırım et al., 2010; Dubey et al., 2010; Kumar, 2010; Agida and Kumar, 2010). According to this protocol, a set of m experimental measured values of the transmittance-reflectance vector: $(T_i(\tilde{\lambda}_i); R_i(\tilde{\lambda}_i))_{i=1..m}$

versus the normalized wavelength $\tilde{\lambda}_i|_{i=1..m}$ is established. Then the system (4) is set:

$$\left\{ \begin{array}{l} R(\tilde{\lambda}) = \left[\frac{1}{2N_0} \sum_{n=1}^{N_0} \xi_n \times B_{4n}(\tilde{\lambda} \times \beta_n) \right] \\ T(\tilde{\lambda}) = \left[\frac{1}{2N_0} \sum_{n=1}^{N_0} \xi'_n \times B_{4n}(\tilde{\lambda} \times \beta_n) \right] \end{array} \right. \quad (4)$$

where β_n are the $4n$ -Boubaker polynomials B_{4n} minimal positive roots (N_0 is a given integer and ξ_n and ξ'_n are coefficients determined through Boubaker Polynomials Expansion Scheme *BPES*).

Finally, the normalized absorbance spectrum $\alpha(\tilde{\lambda})$ is calculated using the relation (5) :

$$\alpha(\tilde{\lambda}) = \frac{1}{d\sqrt{2}} \sqrt{\left(\ln \frac{1-R(\tilde{\lambda})}{T(\tilde{\lambda})} \right)^2 + \left(\ln \frac{(1-R(\tilde{\lambda}))^2}{T(\tilde{\lambda})} \right)^2} \quad (5)$$

where d is the layer thickness.

The effective absorptivity $\hat{\alpha}$ is calculated using (Eq. 3) and (Eq. 5).

3.2.2 The Optothermal expansivity ψ_{AB}

The Amlouk-Boubaker optothermal expansivity unit is m^3s^{-1} . This parameter, as calculated in Eq. (1) can be considered either as the total volume that contains a fixed amount of heat per unit time, or a 3D expansion velocity of the transmitted heat inside the material.

3.2.3 The optimizing-scale 3-D Abacus

According to precedent analyses, along with the definitions presented in § 3.2, it was obvious that any judicious material choice must take into account simultaneously and conjointly the three defined parameters: the band gap E_g , Vickers Microhardness H_v and The Optothermal Expansivity ψ_{AB} . The new 3D abacus (Fig. 2) gathers all these parameters and results in a global scaling tool as a guide to material performance evaluation.

Fig. 2. The 3D abacus

For particular applications, one had to ignore one of the three physical parameters gathered in the abacus. The following 2D projections have been exploited:

The projection in H_v - E_g plane, which is interesting in the case of a thermally neutral material.

It is the case, i.e. of the $\text{ZnS}_{1-x}\text{Se}_x$ compounds, it is obvious that the consideration of Band gap-Hardness features is more important than thermal properties. The E_g - H_v projection (Fig. 3) gives relevant information: the selenization process causes a drastic loss of hardness in initially hard binary Zn-S material.

Fig. 3. The 3D abacus (E_g - H_v projection)

This projection in ψ_{AB} - E_g plane is suitable for thick layers whose mechanical properties don't contribute significantly to the whole disposal hardness.

Fig. 4. The 3D abacus (ψ_{AB} - E_g projection)

The projection in ψ_{AB} - Hv plane is useful for distinguishing resistant and good heat conductor materials, which is the case of the ZnIn_2S_4 materials.

In fact the effect of the Zinc-to-Indium ratio on the values of the Amlouk-Boubaker optothermal expansivity (Fig. 5) is easily observable in this projection (it is equivalent to an expansion of the values of the parameter ψ_{AB} into a wide range: $[10-20] \cdot 10^{-11} \text{ m}^3\text{s}^{-1}$).

Fig. 5. The 3D abacus (ψ_{AB} - Hv projection)

3.3 Investigation of the selected materials

According to the information given by the 3D abacus (Figures 3-5), some materials have been selected. ZnO and ZnO-doped layered materials, SnO_2 and $\text{SnO}_2\text{:F/SnO}_2\text{:F-SnS}_2$ compounds were among the most interesting ones.

3.3.1 ZnO and ZnO-doped layers

Zinc oxide (ZnO) is known as one of the most multifunctional semiconductor material used in different areas for the fabrication of optoelectronic devices operating in the blue and ultra-violet (UV) region, owing to its direct wide band gap (3.37 eV) at room temperature and large exciton binding energy (60 meV) (Coleman & Jagadish, 2006). On the other hand, it is one of the most potential materials for being used as a TCO because of its high electrical conductivity and high transmission in the visible region (Fortunato et al., 2009).

Zinc oxide can be doped with various metals such as aluminium (Benouis et al., 2007) indium (Benouis et al., 2010), and gallium (Fortunato et al., 2008). The conditions of deposition and the choice of the substrate are important for the growth of the films (Benhaliliba et al., 2010). The substrate chosen must present a difference in matching lattice less than 3% to have good growth of the crystal on the substrate (Teng et al., 2007; Romeo et

al., 1998). ZnO (both doped and undoped) is currently used in the copper indium gallium diselenide (CIGS, or Cu (In, Ga)Se₂) thin-film solar cell (Wellings et al., 2008; Haung et al., 2002). ZnO is also promising for the application in the electronic and sensing devices, either as field effect transistors (FET), light sensor, gas and solution sensor, or biosensor.

In addition to its interesting material properties motivating research of ZnO as semiconductor, numerous applications of ZnO are well established. The world usage of ZnO in 2004 was beyond a million tons in the fields like pharmaceutical industry (antiseptic healing creams, etc.), agriculture (fertilizers, source of micronutrient zinc for plants and animals), lubricant, photocopying process and anticorrosive coating of metals.

In electronic engineering, Schottky diode are the most known ZnO-based unipolar devices. The properties of rectifying metal contacts on ZnO were studied for the first time in the late 60ties (Mead, 1965; Swank, 1966; Neville & Mead, 1970) while the first Schottky contacts on ZnO thin films were realized in the 80ties (Rabadanov et al., 1981; Fabricius et al., 1986).

The undoped and doped ZnO films grow with a hexagonal würtzite type structure and the calculated lattice parameters (a and c) are given in Table 1 (Benhaliliba et al. 2010).

Nature	Grain Size (Å)	Int. (%)	d (Å)	2θ (°)	Angle Shift (°)	TC	a (Å)	c (Å)	(c-c ₀)/c ₀ (x10 ⁻⁵)
Undoped									
(100)	217	6.3	2.81	31.78	0.009	0.50	3.24	5.20	-61.4
(002)	358	25.7	2.60	34.44	-0.019	2.33			
(101)	254	19.4	2.47	36.24	-0.008	1.67			
IZO									
(100)	239	100	2.81	31.80	-0.050	2.24	3.24	5.20	-3.84
(002)	211	53.5	2.60	34.42	-0.019	1.19			
(101)	195	85.5	2.47	36.28	-0,028	1.95			
AZO									
(100)	206	70.7	2.81	31.80	-0.011	1.52	3.24	5.20	-115.23
(002)	225	70.5	2.60	34.46	-0.039	1.48			
(101)	195	100	2.47	36.28	-0.028	2.13			

Table 1.

Many significant differences were observed for the undoped, Al- and In-doped ZnO thin films. The films with low thickness (150 nm) have a random orientation with several peaks as reported by Wellings et al. (2008), Ramirez et al. (2007) and Abdullah et al. (2009). The same kind of growth was obtained by Tae et al. (1996) for 150 nm thick films. Whereas on FTO, the predominant ZnO film grew to a thickness of 200-300 nm as stated by Schewenzer et al. (2006). Figures (6-8) give some information about some information about ZnO and ZnO-doped layers.

Fig. 6. Transmittance spectra, ZnO/Glass and ZnO/FTO (a), AZO/Glass and AZO/FTO (b), IZO/Glass and IZO/FTO (c).

Fig. 7. Photoconductivity spectra versus time of ZnO/FTO (d), AZO/FTO (e), IZO/FTO (f).

Fig. 8. SEM micrographs for (a) ZnO, (b) AZO and (c) IZO films, (bottom) white horizontal dashes indicate the scale (100 nm (ZnO), 1 μ m (AZO and IZO)).

3.3.2 SnO₂:F-SnS₂ gradually grown layers

Tin oxide (SnO₂) is an *n*-type VI.II oxide semiconductor with a wide band gap ($E_g = 3.6$ eV). Because of its good opto-electrical properties, and its ability to induce a high degree of charge compensation, it is widely used as a functional material for the optoelectronic devices, gas sensor, ion sensitive field effect transistors, and transparent coatings for organic light emitting diodes (Onyia & Okeke, 1989; Wang et al., 2006; Lee & Park, 2006; Yamada et al., Kane & Schweizer, 1976).

In the last decades, pure and doped tin oxide compounds, prepared by several techniques (Manorama et al., 1999; Bruno et al., 1994; Brinzari et al., 2001; Wang et al., 2002) have been used for the preparation of high performance gas sensing and light emitting devices layers (Barsan, 1994; Goepel & Schierbaum, 1995; Ramgir et al., 2005).

SnO₂ thin films are generally prepared using methanol CH₄O: 1.0 L, demineralised water and anhydrous tin tetrachloride SnCl₄. Formation of pure SnO₂ is resulting from the endothermic reaction:

Approximately 0.9 μ m-thick SnO₂ thin films are generally deposited on glass, under an approximated substrate temperature $T_s = 440^\circ\text{C}$.

XRD patterns of the as-grown SnO₂ films are shown in Fig. 9. Diagram analysis shows that the layers present a first set of (110)-(101)-(200) X-ray diffraction peaks followed by more important pair (211)-(301). According to JCDPS 88-0287 (2000) standards, these patterns refer to tetragonal crystalline structure.

It was reported by Yakuphanoglu (2009) and Khandelwal et al. (2009) that SnO₂ films structure depends wholly on elaboration technique, substrate material and thermal treatment conditions. This feature was also discussed by Purushothaman et al. (2009) and Kim et al. (2008) who presented temperature-dependent structure alteration of the SnO₂ layers.

Atomic force microscopy (AFM) 3D images of the SnO₂ are presented in Fig. 10.

The layers present a pyramidal-clusters rough structure, which is characteristic to many Sn-like metal oxides. This observation confirms the XRD results.

Fig. 9. XRD Diagram of SnO_2 thin layers prepared at T_s 440 °C.

Fig. 10. SnO_2 layers 3D and 2D surface topography 2D (top) and 3D (bottom).

$\text{SnO}_2\text{:F-SnS}_2$ gradually grown layers have as intermediate precursors $\text{SnO}_2\text{:F}$ layers obtained by spray pyrolysis on glass substrates according to the coupled reactions :

and

In the second reaction, ammonium florid acts on the deposited (and heated) tin tetrachloride by incorporation process due to ionic close electro-negativity and dimension (F^- and O^{2-} radii ratio is around 0.96). The obtained layers are n-type (Fig 11-a)

Hence, the first step of the protocol is indeed elaboration of the precursor $\text{SnO}_2:\text{F}$ layer. In the second step, this layer is subjected to local annealing in a highly sulfured atmosphere (Fig 11-b). Under specific experimental conditions (Temperature, pressure, exposure time) SnS_2 compound appears selectively at the top of the precursor $\text{SnO}_2:\text{F}$ layer. This obtained mini-layer is n-type (fig 11-b).

Fig. 11. TCO monolayer-grown: cell elaboration protocol

Finally, a neutral masking sheet is applied to the free surface in order to deposit copper (Cu) by evaporation, controlled dipping or even direct mechanical spotting. Due to the metallic diffusive properties, a multiphase CuSnS ($\text{Cu}_2\text{SnS}_3, \text{Cu}_3\text{SnS}_4, \text{Cu} \dots$) conducting compound appears at the free surfaces (Fig 11-c). This compound has been verified to have better mechanical performance than CuInS .

3.3.3 A sketch of the thermally optimized new monolayer grown cell

The first prototype of the proposed TCO monolayer-grown Solar cell is presented in Figure 12. The procedure can be applied to other oxides, namely Sb_xO_y , $\text{Sb}_x\text{S}_y/\text{MSbO}$ ($\text{M}=\text{Cu}, \text{Ag}, \dots$) hetero-junction.

It has been experimented that n-type can be locally and partially transformed into p-WS₂, which results in a WO₃/WS₂ heterojunction, using the same sulfuration procedure detailed above.

Fig. 12. TCO monolayer-grown Solar cell

The case of ZnO has been experimented but raised some problems, in fact it has been recorded that sulfuration process is never complete, and that an unexpected mixture (ZnO)_x(ZnS)_y takes place.

4. Conclusion

In this chapter, a new physical parameter has been proposed as a guide for optimizing the recently implemented oxide monolayer spray-grown solar cells. This parameter led to the establishment of a 3D (bangap E_g -Vickers Microhardness H_v -Optothermal Expansivity ψ_{AB}) abacus. Thanks to optimizing features, some interesting materials have been selected for an original purpose: The TCO monolayer-grown Solar cell. The first prototype of the proposed TCO monolayer-grown Solar cell has been presented and commented. The perspective of using other oxides, namely Sb_xO_y, Sb_xS_y/MSbO (M=Cu, Ag,...) has been discussed.

5. References

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The fourth book of the four-volume edition of 'Solar cells' consists chapters that are general in nature and not related specifically to the so-called photovoltaic generations, novel scientific ideas and technical solutions, which has not properly approved. General issues of the efficiency of solar cell and through hydrogen production in photoelectrochemical solar cell are discussed. Considerable attention is paid to the quantum-size effects in solar cells both in general and on specific examples of super-lattices, quantum dots, etc. New materials, such as cuprous oxide as an active material for solar cells, AlSb for use as an absorber layer in p-i-n junction solar cells, InGaAsN as a promising material for multi-junction tandem solar cells, InP in solar cells with MIS structures are discussed. Several chapters are devoted to the analysis of both status and perspective of organic photovoltaics such as polymer/fullerene solar cells, poly(p-phenylene-vinylene) derivatives, photovoltaic textiles, photovoltaic fibers, etc.

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Slavka Krautzeka 83/A
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Phone: +86-21-62489820
Fax: +86-21-62489821

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